

(12) United States Patent

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(54) MICROFABRICATED SENSOR AND A METHOD OF SENSING THE LEVEL OF A COMPONENT IN BODILY FLUID

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- patent is extended or adjusted under 35 U.S.C. 154(b) by 385 days.
- (21) Appl. No.: $14/649,422$
- (22) PCT Filed: Nov. 29, 2013
- (86) PCT No.: PCT/SE2013/051416 OTHER PUBLICATIONS \S 371 (c)(1),
(2) Date: **Jun. 3, 2015**
- (87) PCT Pub. No.: WO2014/088493 PCT Pub. Date: Jun. 12, 2014

(65) **Prior Publication Data**

US 2015/0313527 A1 Nov. 5, 2015

(30) Foreign Application Priority Data

Dec . 7 , 2012 (SE) 1200754

(51) **Int. Cl.**
 $A6IB 5/00$ (2006.01)
 $A6IB 5/15$ (2006.01) (2006.01)

(Continued)

(52) U.S. Cl.

CPC $A61B5/150282$ (2013.01); $A61B5/0507$ $(2013.01);$ $A6IB$ 5/14514 (2013.01); (Continued)

(10) Patent No.: US $9,949,679$ B2
(45) Date of Patent: Apr. 24, 2018

(45) Date of Patent:

- USPC 600 / 365 (58) Field of Classification Search See application file for complete search history.
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(*) Notice: Subject to any disclaimer, the term of this (Continued)

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(57) ABSTRACT

The disclosure relates to a microfabricated sensor (1) comprising at least one hollow microneedle (2) for minimal invasive extraction of a sample of bodily fluid, a fluid channel (3) connected to the at least one microneedle for receiving a sample of bodily fluid extracted by the at least one microneedle, a microwave transmission line (4) coupled to and extending along at least a portion of the fluid channel, such that the dielectric properties of the fluid in the fluid channel provide an influence on the electrical properties of the transmission line. The disclosure further relates to a method of microfabricating such a sensor and a method of sensing the level of a component in bodily fluid of a patient by providing such a sensor.
34 Claims, 4 Drawing Sheets

 (51) Int. Cl.

(52) U.S. Cl.
CPC $A61B\ 5/14525\ (2013.01)$; $A61B\ 5/14532$ (2013.01) ; $A6IB \overline{S/150351}$ (2013.01) ; $A6IB$ 5/150984 (2013.01); A61B 5/6826 (2013.01); **A61B 10/0045** (2013.01); A61B 5/150022 (2013.01); A61B 5/150068 (2013.01); A61B 5/15105 (2013.01); A61B 5/15186 (2013.01); A61B 5/150389 (2013.01); A61B 5/150503 $(2013.01);$ $A61B$ $2010/008$ $(2013.01);$ $A61B$ 2562/125 (2013.01)

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Fig. 1

Fig. 3a

Fig. 5

Fig. 6

10

the glucose level in the body, preferably in a small amount direction, around a circumference of the microneedle. The at of body fluid. The most common method to determine the least one opening may be provided about midway of body fluid. The most common method to determine the least one opening may be provided about midways along a
blood glucose level is to use disposable glucose test strips longitudinal extension of the microneedle. Thereby blood glucose level is to use disposable glucose test strips longitudinal extension of the microneedle. Thereby the and a glucose meter, see U.S. Pat. No. 5,951,836. To extract $_{20}$ extraction of bodily fluid is facilit and a glucose meter, see U.S. Pat. No. 5,951,836. To extract $_{20}$ extraction of bodily fluid is facilitated and the risk for blood, a lancet pricks the finger and a drop of blood is placed clogging is further reduced. on the strip. The main drawback with the glucose test strips The capillary bore of the at least one microneedle may be is the pain from the extraction of blood using the lancet as provided with a hydrophilic surface. There is the pain from the extraction of blood using the lancet as provided with a hydrophilic surface. Thereby capillary suc-
well as the skin damage.
well as the skin damage.

non-invasive method ("see The Pursuit of Noninvasive microneedle. Thereby the skin may be cut and opened to Glucose: Hunting the Deceitful Turkey", John L. Smith, facilitate extraction of bodily fluid. Second edition 2011). Measurement techniques range from The at least one microneedle may have a length of spectroscopic optical light scattering breath and transder, 30 200-1000 µm, preferably 400-900 µm, more preferably spectroscopic, optical, light scattering, breath and transder $\frac{30 - 200 - 1000}{500 - 600}$ µm, preferably 400-900 µm, more preferably mal techniques. Techniques foil primarily due to difficulties $\frac{500 - 600}{500 - 600}$ µ mal techniques. Techniques fail primarily due to difficulties 500-600 µm, and an outer diameter of 50-200 µm, preferably
to obtain an accurate glucose measurement. It has been 60-150 µm. Thereby the microneedle has dimensi to obtain an accurate glucose measurement. It has been $\frac{80-150 \text{ }\mu\text{m}}{80-150 \text{ }\mu\text{m}}$. Thereby the microneedle has dimensions suit-
able for penetration of the skin and extraction of bodily fluid. shown that the glucose level in interstitial fluid (ISF) cor-
able fluid channel may have an extension in a channel relates well to the blood glucose level (Suresh et al. "Com-
parison of glucose concentration in interstitial fluid, and ³⁵ plane, in wherein the microneedles protrude in a direction parison of glucose concentration in interstitial fluid, and ³⁵ plane, and wherein the microneedles protrude in a direction
capillary and venous blood during rapid changes in blood
glucose levels", Vol 3, No 3, 2001, Diab

to minimize discomfort is a rapidly developing arena of
investigation for the transcutaneous delivery of drugs. Such
microneedles have been developed for extracting ISF trans-
dermal, see U.S. Pat. No. 7,753,888.
Spiral. T

sensor for detecting a component in bodily fluid, where the Thereby the fluid channel may be filled with bodily fluid sensor provides for a rapid and accurate detection of a 50 from the central portion and outward, prefera sensor provides for a rapid and accurate detection of a 50 from the central portion and outward, gomponent in bodily fluid.

comprising at least one hollow microneedle for extraction of surface. Thereby capillary suction of bodily fluid may be a sample of bodily fluid, a fluid channel connected to the at assisted. least one microneedle for receiving a sample of bodily fluid 55 The sensor may comprise a plurality of hollow extracted by the at least one microneedle, a microwave microneedles. Thereby the filling of the fluid channel wi extracted by the at least one microneedle, a microwave microneedles. Thereby the filling of the fluid channel with transmission line coupled to and extending along at least a bodily fluid may be optimized. portion of the fluid channel, such that the dielectric proper-
the microneedles may be distributed along a portion of
ties of the fluid in the fluid channel provide an influence on
the channel, preferably a central portion

fluid is provided, which sensor provides for a rapid and enclosed cavity where the enclosure comprises an electrical accurate detection of a component in bodily fluid, such as conductive material and the cavity is formed s accurate detection of a component in bodily fluid, such as conductive material and the cavity is formed such that it has ISF or blood. The microfabricated sensor may be integrated an electrical conductor placed inside in a ISF or blood. The microfabricated sensor may be integrated an electrical conductor placed inside in a way that there is no in hand held devices. There may also be minimal damage to 65 direct contact between the enclosure a biological tissues at the point of entrance of the micromeedle, The fluid channel may form a RF (i.e. radiofrequency, and the discomfort of the patient may be reduced. microwave) cavity of the microwave transmission line.

MICROFABRICATED SENSOR AND A The microwave transmission line may extend along the **METHOD OF SENSING THE LEVEL OF A** full length of the fluid channel, thus increasing the sensitiv-**THOD OF SENSING THE LEVEL OF A** full length of the fluid channel, thus increasing the sensitiv-

COMPONENT IN BODILY FLUID ity of the device.

The at least one microneedle may comprise a capillary
TECHNICAL FIELD ⁵ bore, e.g. a single capillary bore. Thereby bodily fluid may bore, e.g. a single capillary bore. Thereby bodily fluid may be extracted by means of capillary suction . Alternatively , or The present invention relates generally to a microfabri-

in addition, a suction force may be applied to the fluid

cated sensor and a method of sensing the level of a com-

channel and the at least one hollow microneedle channel and the at least one hollow microneedle to extract bodily fluid. ponent in bodily fluid.

¹⁰ The at least one microneedle may be provided with a cap

BACKGROUND ART

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STERN AT A distalled for shielding the capillary bore from clogging,

whereby at least one opening to the capi

Other methods to measure the glucose level have been 25 The microneedle may comprise a plurality of cutting suggested in the prior art. The main goal is to develop a elements extending along a longitudinal direction of the

spiral. Thereby a first and second end portion may be 45 accessed at a radially outer portion of the spiral.

53 SUMMARY OF INVENTION The central portion may be S-shaped.
The at least one microneedle may be arranged at and
An objective of the present invention is to provide a connected to a central portion of the spiral channel po

Thus the invention relates to a microfabricated sensor The fluid channel may be provided with a hydrophilic comprising at least one hollow microneedle for extraction of surface. Thereby capillary suction of bodily fluid ma

the electrical properties of the transmission line.
Thereby a sensor for detecting a component in bodily
waveguide, a stripline, microstrip or a partially or fully waveguide, a stripline, microstrip or a partially or fully

The microwave transmission line may comprise a spiral The microneedles may be formed in the channel wafer by transmission line portion. Thereby the footprint of the sensor a deep reactive ion etching, possibly combined wit

transmission mode RF spectroscopy. Thereby measurements ⁵ The invention further relates to a method of detecting
of the dielectric properties of bodily fluid in the fluid channel and/or measuring a component in bodily fl

range of 10-100 μ m, preferably in the range of 25-75 μ m. extracting a sample of bodily fluid by means of the at least
Thereby the capillary and fluidic properties of the channel 10 one hollow microneedle,

measurement accuracy of the sensor may be high enough. $_{15}$

microneedle may be fabricated in the channel plate, prefer-
ably a component in bodily fluid may be rapidly and
accurately detected and/or measured by a minimally inva-
accurately detected and/or measured by a minimally in

chining, resulting in a high dimensional accuracy of the The method may comprise determining the level of the structures of the sensor, formed in a material suitable for component based on the performed swept frequency or structures of the sensor, formed in a material suitable for component based on the performed swept frequency or biomedical devices having very good mechanical properties, pulsed measurement.

surrounded by a frame structure dimensioned to support the detecting an output signal at a second end of the transmistip of a finger. The frame structure dimensioned to support sion line. tip of a finger. The frame structure dimensioned to support sion line.
the tip of a finger may be a ring shaped structure protruding The swept frequency or pulsed measurement may com-
along the longitudinal direction of th microneedle. Thereby the skin may be stretched by the 30 electrical signal. supporting structure, such that penetration of the The fluid channel may be configured such that the elec-
microneedles through the skin is facilitated.

transmission line substrate plate, preferably a glass wafer or nents within the bodily fluid
a silicon wafer. $\frac{35}{2}$ The swept frequency meas

assembling the channel wafer and the transmission line transform (FFT) of the output signal on a second end of the substrate wafer such that the microwave transmission line is transmission line. The measurement may compris substrate wafer such that the microwave transmission line is transmission line. The measurement may comprise a com-
coupled to and extending along at least a portion of the fluid 50 parison of the input and output signal t coupled to and extending along at least a portion of the fluid 50 parison of the input and output signal thus detecting the channel.

fluid is provided, which sensor is minimally invasive and pulse may be a square pulse with a known or unknown provides for a rapid and accurate detection of a component amplitude. provides for a rapid and accurate detection of a component
in blood. The method allows for a microfabricated sensor 55 The bodily fluid may be blood and/or interstitial fluid.
which may be manufactured at reduced cost.
The

electrical ports, one input port and one output port, with electrical contacts, that may contain any combination of ground and two signals, most preferably a geometrical 60 The invention is now described, by way of example, with structure of ground-signal-ground-signal-ground or ground-
reference to the accompanying drawings, in which: structure of ground-signal-ground-signal-ground or ground-
signal-signal-ground. Ground and signal contacts may be FIG. 1 shows a microfabricated sensor in perspective signal-signal-ground. Ground and signal contacts may be
made by means of wire bonding, ribbon bonding, probing,
connectors and/or conductive epoxy to read out electronics.
FIG. 2 shows a microfabricated sensor in a cross-s

transmission line substrate wafer may be a glass wafer, FIG $3a$ shows a central portion of the fluid channel and which wafers are assembled by bonding. which wafers are assembled by bonding.

ay be limited.
The microwave transmission line may be configured for may be microfabricated in the silicon material.

may be performed in a simple manner.
The fluid channel may have a width and/or height in the providing a microfabricated sensor as disclosed herein,

may be optimal.
The fluid channel may have a length in the range of 1-50 receiving the fluid sample in the fluid channel,
mm, preferably in the range of 20-40 mm. Thereby the the fluid sample by means of the microwave tran the fluid sample by means of the microwave transmission line. and

The fluid channel may be microfabricated in a channel detecting and/or measuring the component based on the plate, preferably a silicon wafer. The at least one performed swept frequency or pulsed measurement.

Iy in silicon.
Thereby the sensor may be formed by silicon microma- $_{20}$ sive method using the sensor as disclosed herein.

and suitable for batch fabrication.
The measurement may comprise injecting an input elec-
The at least one microneedle may be at least partly 25 trical signal at a first end of the transmission line and The at least one microneedle may be at least partly 25 trical signal at a first end of the transmission line and surrounded by a frame structure dimensioned to support the detecting an output signal at a second end of the

prise detecting and/or measuring a phase change in an

icroneedles through the skin is facilitated. trical phase as a function of the frequency of the electrical
The microwave transmission line may be fabricated in a signal changes proportionally in respect to certain compo-

silicon wafer.
The swept frequency measurement may comprise detect-
The microfabricated sensor may be a glucose sensor. ing and/or measuring a phase change in the electrical signal The invention further relates to a method of microfabri-
cating a sensor as disclosed herein, comprising
the bodily fluid. The electrical signal may be inserted at a
disclosed herein, comprising ting a sensor as disclosed herein, comprising the bodily fluid. The electrical signal may be inserted at a providing a channel wafer, having a first and a second first end of the transmission line and the phase change may

Face,

etching the at least one microneedle on the channel wafer,

at the swept frequency measurement may be performed

protruding from the first face of the silicon wafer,

etching the fluid channel in the second face of

wafer,

providing a transmission line substrate wafer,

forming the microwave transmission line on the transmis-

forming the microwave transmission line on the transmis-

forming the microwave transmission line on the tra on line substrate wafer,
assembling the channel wafer and the transmission line transform (FFT) of the output signal on a second end of the annel.
Complex portions of the signal in order to detect and/or
Thereby a sensor for detecting a component in bodily
measure the concentration of components in bodily fluid The Thereby a sensor for detecting a component in bodily measure the concentration of components in bodily fluid The fluid is provided, which sensor is minimally invasive and pulse may be a square pulse with a known or unknown

FIG. 3b shows a perspective view of the fluid channel and The spiral portion of the fluid channel 3 and the transmistion line.

In the spiral portion of the fluid channel 3 and the transmistion line.

FIG. **5** shows a perspective view of a microneedle of the $\frac{5}{2}$ sensor.

microneedle of the sensor. The section may alternatively be extended a section may alternate the sensor . The sensor . A plurality of microneedles, in this case nine

microneedles each comprises a single capillary bore, and the 15 accuracy, and a shorter channel provides for a sensor further comprises a fluid channel 3 (not visible in footprint and thus a reduced cost of manufacture. FIG. 1, see e.g. FIG. 2) connected to the microneedles for In FIG. 3b a perspective view of a fluid channel entry receiving a sample of bodily fluid extracted by the $3a/3b$ and the connectors forming the transmission lin through a first $3a$ and a second $3b$ fluid channel opening to 20 enable capillary suction of the bodily fluid. The term minienable capillary suction of the bodily fluid. The term mini-
maily invasive implies that there is minimal damage to cross-sectional dimensions provide for suitable fluidic and biological tissues at the point of entrance of the microneedles, thus reducing the discomfort of the patient.

line 4 (not visible in FIG. 1, see e.g. FIG. 2) coupled to and
extending along at least a portion of the fluid channel, such
that the dielectric properties of the fluid in the channel of the ground conductor in the transmi that the dielectric properties of the fluid in the channel of the ground conductor in the transmission line formed provide an influence on the electrical properties of the along the channel. The width w of the center condu provide an influence on the electrical properties of the transmission line. The microwave transmission line 4 com - 30 about 20 μ m, and the width of each insulting track 12 is thus prises a center conductor 5, electrically connected by a first about $15 \mu m$. The fluid channel thus forms a RF cavity of the $5a$ and a second $5b$ electrical contact pad, forming a first and transmission line. a second electrical port of the transmission line, and a In FIG. 4 a cross-section of one of the microneedles 2 is ground plane 6. The contact pads $5a$, $5b$ and a contact pad shown supported by the channel plate 7 formin of the ground plane 6 are positioned on an edge portion of 35 the sensor to facilitate electrical connection of the sensor.

plate 8, bonded together. The channel plate supports the portion 13 forming the base of the needle connected to the plurality of microneedles 2 protruding from a microneedle channel plate. The base forms within itself a ca support surface 9 of the channel plate. The fluid channel 3 40 14 in fluid transferring contact with the fluid channel 3. The is formed in the opposite surface of the channel plate as microneedle has a longitudinal extensi compared to the microneedle support surface. The direction, and comprises a tip portion 15 at distal end of the microneedles protrude in a direction perpendicular to the needle. The tip portion comprises a cap 16 for shiel microneedles protrude in a direction perpendicular to the needle. The tip portion comprises a cap 16 for shielding the microneedle support surface and a channel plane, in which capillary bore from clogging during penetrati

ture is in the range of 1-10 mm and is thus dimensioned to An example of a microneedle 2 is further shown in FIG.
support the tip of a finger. The tips of the microneedles are 5. The microneedle has an elongated shape with protected by the upper surface of the ring shaped frame 50 structure, such that they do not protrude beyond this upper surface. Thus the needles are protected from breakage during fabrication and handling of the sensor, and the sensor may be sealed by a protective film during fabrication and capillary bore. The tip portion is supported in the base
handling. The ring shaped structure has the effect that the 55 portion by a set of elongated elements **18** handling. The ring shaped structure has the effect that the 55 portion by a set of elongated elements 18 forming a plurality skin of the tip of a finger pressed towards the microneedles of openings 17 around the circumfere may be brought into tension, thereby facilitating the pen-
These elongated elements extend along the longitudinal

Turning to FIG. 2, the fluid channel 3 and transmission line 4 is shown in a cross-section between the channel plate ω line 4 is shown in a cross-section between the channel plate 60 In FIG. 6 a microneedle is shown in three different and the substrate plate. As shown in the figure, the fluid cross-sections A-A, B-B and C-C. In cross-secti and the substrate plate. As shown in the figure, the fluid cross-sections A-A, B-B and C-C. In cross-section A-A the channel and transmission line co-extend and comprises the base portion 13 is shown to form a capillary bo channel and transmission line co-extend and comprises the base portion 13 is shown to form a capillary bore 14 for
form of a double spiral shape having an S-shaped center transporting fluid to the fluid channel. The cap 16 portion 11 where the shape turn from a first spiral portion of ported by a plurality of elongated elements 18. In the the double spiral, to a second spiral portion of the double 65 example shown the number of elongated ele the double spiral, to a second spiral portion of the double 65 spiral. The spiral portion of the fluid channel defines a spiral. The spiral portion of the fluid channel defines a the number of elongated elements may be in the range of channel plane.
2-20. In sections B-B and C-C it is shown that the elongated

6

the interpretation line and is similar than the 4 is further disclosed in FIG. 3a. The transmis-
FIG. 4 shows a cross-sectional view of a microneedle of sion line comprises a center connector 5 electrically sepasion line comprises a center connector 5 electrically sepathe sensor.
FIG. 5 shows a perspective view of a microneedle of the s 12 on each side of the center connector. The fluid channel 3 sensor.
Sensor typically has a rectangular cross-section, but the cross-
FIG. 6 shows various cross-sectional views of a section may alternatively be e.g. triangular or semi-circular.

microneedles, are connected to the S-shaped center portion DESCRIPTION OF EMBODIMENTS 10 of the fluid channel, distributed over this center portion at a distance from each other, to facilitate penetration of the skin.

In FIGS. 1 and 2, a microfabricated sensor 1 is shown The fluid channel length is typically about 30 mm, e.g. comprising a plurality of hollow microneedles 2 for minimal 10-50 mm, preferably 20-40 mm. This is a trade-off b

shown. The width wg of the fluid channel, in the channel plane, is typically about 50 μ m, and the height h of the fluid cross-sectional dimensions provide for suitable fluidic and capillary properties as well as suitable electrical properties explore the sensor further comprises a microwave transmission 25 herein of the fluid channel/RF cavity.
The sensor further comprises a microwave transmission 25 herein of the fluid channel/RF cavity.

shown supported by the channel plate 7 forming the fluid channel 3. The substrate plate 8 connected to the channel the sensor to facilitate electrical connection of the sensor. plate is further shown, supporting the center connector 5 of The sensor is formed by a channel plate 7 and a substrate the transmission line. The microneedle co The sensor is formed by a channel plate 7 and a substrate the transmission line. The microneedle comprises a base plate 8, bonded together. The channel plate supports the portion 13 forming the base of the needle connected channel plate. The base forms within itself a capillary bore 14 in fluid transferring contact with the fluid channel 3. The microneedle support surface and a channel plane, in which capillary bore from clogging during penetration. A plurality the fluid channel extends. 45 of openings 17 are provided in several lateral directions the fluid channel extends.

A ring shaped frame structure 10 surrounds the around the circumference of the microneedle, about mid-A ring shaped frame structure 10 surrounds the around the circumference of the microneedle, about mid-
microneedles. The inner diameter of the ring shaped struc-
ways along the longitudinal direction of the microneedle.

drical and forms a capillary bore 14. The base portion has a diameter that may be narrowed down in a direction towards the tip. The tip portion comprises a cap 16 for shielding the etration of the microneedles through the skin. direction of the microneedle and also functions as cutting Turning to FIG. 2, the fluid channel 3 and transmission elements for cutting the skin.

2-20. In sections B-B and C-C it is shown that the elongated

microneedles 2 and supported by the ring-shaped frame 5 structure 10. The skin is then stretched by the supporting structure 10. The skin is then stretched by the supporting centimeter, including feature sizes down to sub-microm-
structure, such that penetration of the microneedles through eters. Micromachining may include one or more structure, such that penetration of the microneedles through eters. Micromachining may include one or more of lithog-
the skin is facilitated. The microneedles are penetrated into raphy, wet etching, dry etching (such as d the skin by cutting the skin by means of the sharp tip portion etching, DRIE) etc, but may further include one or more of of the needle, and by means of the elongated cutting 10 electron or ion bean machining, plasma beam elements 18. Bodily fluid in or underneath the skin of the laser machining, electro discharge machining, micromilling, finger is extracted by means of the plurality of openings 17 micromolding, microreplication in a polyme interstitial fluid. The bodily fluid is extracted by capillary ing and the like. Micromachining allows for a miniaturised suction forces into the capillary bore 14. The cap 16 reduces 15 device that may be batch fabricated suction forces into the capillary bore 14 . The cap 16 reduces 15 device that m the risk of the capillary bore of the microneedles are clogged reduced cost.

ported by capillary action into the spiral portion of the fluid firstly. The first step in the lithography is to prime the wafers channel 3 where it forms a dielectric medium in the RF 20 in a HMDS oven. This gives a bette transmission line, in contact with the central conductor 5 and which is later coated on the wafer. As a side effect, the wafer the ground plane 6 in the fluid channel. will also be hydrophobic.

The RF transmission line is configured for transmission The next step in the lithography is the resist coating, such measurements. In an alternative configuration, the RF trans- as with a positive resist. mission line may be configured for reflection measurements 25 The following step in the lithography is to create the of the properties of the transmission line. In this alternative pattern on the wafer, so the etching patt of the properties of the transmission line. In this alternative pattern on the wafer, so the etching pattern may be created configuration the transmission line is provided with a ter-
later. A mask for the different etchin configuration the transmission line is provided with a ter-
mination resistance at the reflection end of the transmission wafer is exposed with UV light creating a pattern in the mination resistance at the reflection end of the transmission wafer is exposed with UV light creating a pattern in the line (i.e. the central portion of the spiral). The dielectric resist. The resist (with the pattern) wor properties of the bodily fluid received in the fluid channel 30 the etching, this allows the wafer to be etched and only the may be analyzed by means of analyzing the RF signal in the wanted pattern is created and the resi may be analysed by means of analyzing the RF signal in the wanted phase domain to identify changes in the phase.

frequency above 1 GHz, preferably above 4 GHz, more baked. The purpose of hard baking is to remove residual preferably above 8 GHz. In one example the RF measure- 35 solvent and to improve the adhesion of the resist so it preferably above 8 GHz. In one example the RF measure- 35 solvent and to improve the ment is performed at a center frequency of 8 GHz. By protect the wafer enough. performing the measurement at high frequency, the mea-
Surement at surement accuracy may be high.
This is carried out to remove the resist and to access the next mask. This is

electrical signal of constant amplitude into the input port, i.e. α ilicon etching may be carried out with the first port $5a$. The frequency is swept with a center is covered by the previous resist mask. frequency, e.g. above 1 GHz, preferably above 4 GHz, more Oxide stripping is done by dipping the wafer in 50% HF preferably above 8 GHz, and with a sweep range preferably and is done to remove the oxide layer. When forming preferably above 8 GHz, and with a sweep range preferably and is done to remove the oxide layer. When forming the needles, oxidation and oxide stripping may be repeated until

may be correlated to and well determined in respect to an The oxide etchings are carried out to create an oxide
empty fluid channel and or a fluid channel filled with a fluid mask, since a resist mask may not be done after empty fluid channel and or a fluid channel filled with a fluid mask, since a resist mask may not be done after a first silicon consisting of know concentrations of the component of etching. Therefore, the second etch patte interest. A phase change when using an unknown but similar resist followed by oxide etch before the first etch pattern is substance will therefore be due to a different concentration 50 created by resist. An oxide etch is substance will therefore be due to a different concentration 50 created by resist. An oxide etch is also carried out to remove of the component of interest in the substance and the the oxide from the wafer, were the silico of the component of interest in the substance and the the oxide from the concentration of the component of interest may be calcu-
place afterwards. lated as it is proportional to the phase of the output signal of The silicon etch creates the actually needles, the fluid an empty fluid channel with an offset as well as proportional channel and the frame structure. The structures are etched in to a previously calibrated fluid channel of the same geom- 55 an Inductively Coupled Plasma (ICP) etry filled with an known substance of similar content.
The phase as a function of the frequency of the electrical

signal injected in one end of the transmission line of an $600-650 \mu m$ double side polished silicon are used. The empty fluid channel or a fluid channel filled with a known wafers are washed and a wet oxidation is followe substance may be determined by theoretical calculations, 60 The first step is the lithography, which includes Hexam-
wafer test or unit test in such way that it may be used as ethyldisilazane (HMDS) oven, resist coating, e wafer test or unit test in such way that it may be used as ethyldisilazane (HMDS) oven, resist coating, exposure, means of calibration.

development and descum. The first mask that is used during

Thereby the presence or concentration of a component in the exposure is the spiral channel mask. This step follows by the bodily fluid may be analysed by means of the disclosed hard baking, an oxide etch and later by a res mine the glucose level in an individual.

elements are narrowed down towards the tip portion of the In the following, a method of microfabricating a sensor is microneedle to form cutting elements for cutting the skin described.

during penetration.

During operation, the tip of a finger is pressed towards the miques of structures in the micrometer range. The final

microneedles 2 and supported by the ring-shaped frame 5 components can be in the or raphy, wet etching, dry etching (such as deep reactive ion

the risk of the material from the finger.
The risk of the microneedles are cost . The lithographic steps of the method of microfabricating . The bodily fluid extracted by the microneedles is trans-
the sensor are performed The bodily fluid extracted by the microneedles is trans-
ported by capillary action into the spiral portion of the fluid
firstly. The first step in the lithography is to prime the wafers

resist. The resist (with the pattern) works as a mask during the etching, this allows the wafer to be etched and only the

The RF measurement may be performed at a center The pattern of the resist is thereafter developed and hard guency above 1 GHz, preferably above 4 GHz, more baked. The purpose of hard baking is to remove residual

surement accuracy may be high.
The RF measurement may be performed by injecting an advantageous, since one mask may be removed and another advantageous, since one mask may be removed and another silicon etching may be carried out with an oxide mask that

In the needles, oxidation and oxide stripping may be repeated until
The phase of the output signal, i.e. on the second port $5b$, 45 a sharp enough tip of the needle is created.

etching. Therefore, the second etch patterns is created by

an Inductively Coupled Plasma (ICP) Deep Reactive Ion Etching (DRIE) apparatus.

The phase as a function of the frequency of the electrical To produce the needles and fluid channel, wafers made of signal injected in one end of the transmission line of an 600-650 μ m double side polished silicon are u

mask. Same step as during the lithography of the fluid channel are carried out.

etching (DRIE) takes place. This result in a etch pattern openings are provided in a late created by the capillary bore mask. A resist stripping results cumference of the microneedle.

wash and wet oxidation) is carried out. The final step on this 10% 8. The sensor according to claim 1 wherein the at least one side of the silicon wafer (the back) is a metal deposition, microneedle has a length of 200 side of the silicon wafer (the back) is a metal deposition, microneedle has a length of $50-200 \mu m$.

the needles. Also as above, hard baking, an oxide etching 10. The sensor according to claim 1 wherein the fluid and resist stripping are all carried out. Channel has an extension in a channel plane, the at least one

followed by an isotropic etching, and later by an anisotropic **11**. The sensor according to claim 10 wherein the at least etching to create the pattern of the base mask. After the two one microneedle is arranged at and con etching to create the pattern of the base mask. After the two one microneedle is arranged at and connected to a central etchings, a resist stripping takes place and the resist base portion of the spiral channel portion.

mask is removed. **12.** The sensor according to claim 1 comprising a plurality
The next step in the process is the oxide etching, followed 25 of hollow microneedles.
by the silicon etching (DRIE) that creates the etch patte

In an oxidation, an oxide stripping again and a new oxidation. 14. The sensor according to claim 1 wherein the micro-
The last step in the process of the silicon wafer is a metal 30 wave transmission line is a coplanar wav

The silicon wafer is now finished and the Pyrex mask is wave transmission line comprises a spiral transmission line used to get the transmission line pattern on the Pyrex wafer. portion. Metal deposition on the Pyrex wafer is done by sputtering, 35 16. The sensor according to claim 1 wherein the micro-
and the process ends with the bonding of the Pyrex wafer wave transmission line is configured for transmi and the process ends with the bonding of the Pyrex wafer wave transmission line is configured for transmission mode and the silicon wafer. The bonded wafer stack is thereafter measurements. and the silicon wafer. The bonded wafer stack is thereafter measurements.
diced into individual sensor components. 17. The sensor according to claim 1 wherein the micro-

- of bodily fluid, a fluid channel connected to the at least **19**. The sensor according to claim 1 wherein the fluid one microneedle for receiving a sample of bodily fluid channel has a length in the range of 1-50 mm.
- along at least a portion of the fluid channel so that 21. The sensor according to claim 20 wherein the at least bodily fluid in the channel forms a dielectric medium in one microneedle is fabricated in the channel plate. tric properties of the fluid in the fluid channel provide 50 one microneedle is at least partly surrounded by a frame an influence on the electrical properties of the trans-
structure dimensioned to support the tip of a fi

2. The sensor according to claim 1 wherein the fluid structure dimensioned to support the tip of a finger is a ring channel is defined by walls, the microwave transmission line shaped structure protruding along the longitu channel is defined by walls, the microwave transmission line shaped structure protruding along the longitudinal direction includes a center conductor and a ground plane, the center 55 of the at least one microneedle. includes a conductor is located between the walls of the fluid channel,

24. The sensor according to claim 1 wherein the micro-

24. The sensor according to claim 1 wherein the micro-

24. The sensor according to claim 1 w

3. The sensor according to claim 1 wherein the at least one 25. The sensor according to claim 1 wherein the micromicroneedle includes a capillary bore, and the at least one 60 fabricated sensor is a glucose sensor. microneedle is provided with a cap at a distal end for **26**. A method of microfabricating a sensor having at least shielding the capillary bore from clogging, whereby at least one hollow microneedle for extraction of a sam shielding the capillary bore from clogging, whereby at least one hollow microneedle for extraction of a sample of bodily one opening to the capillary bore is provided in a lateral fluid, a fluid channel connected to the at one opening to the capillary bore is provided in a lateral fluid, a fluid channel connected to the at least one direction of the microneedle.

microneedle for receiving a sample of bodily fluid extracted

4. The sensor according to claim 3 wherein the at least one 65 by the at least one microneedle, and a microwave transmis-
opening is provided about midways along a longitudinal sion line coupled to and extending along at l

After the first two lithography steps, the first silicon 5. The sensor according to claim 3 wherein a plurality of ching (DRIE) takes place. This result in a etch pattern openings are provided in a lateral direction, aroun

in that the resist bore mask is removed.

6. The sensor according to claim 1 wherein the capillary

After the removal of the Bore mask, the next silicon etch 5 bore of the at least one microneedle and at least part of the

from the spiral channel mask. The sensor according to claim 1 wherein the Yet another time, an oxide stripping takes place and in this microneedle comprises a plurality of cutting elements Yet another time, an oxide stripping takes place and in this microneedle comprises a plurality of cutting elements part of the process, even an oxidation (including standard extending along a longitudinal direction of the

The wafer is then turned around and the rest of the process **9.** The sensor according to claim 1 wherein the microwave takes place at the other side (the front). the side (the front). transmission line is at least substantially coextensive with Lithography is carried out with a five-point star mask for 15 the fluid channel.

d resist stripping are all carried out.
After the lithography of the star mask, a base mask is used incroneedle protrudes in a direction out of the channel After the lithography of the star mask, a base mask is used microneedle protrudes in a direction out of the channel
for the needles and the same lithography process takes place. plane, and the fluid channel comprises a spi for the needles and the same lithography process takes place. plane, and the fluid channel comprises a spiral channel A hard baking and an oxide etch is carried out. This is 20 portion.

e Star mask.
Thereafter an oxide stripping is performed, followed by channel.
Channel.

deposition of the back of the wafer. The metal may be e.g. or a microstrip.
gold.
The sensor according to claim 1 wherein the micro-
The silicon wafer is now finished and the Pyrex mask is wave transmission line comprises

wave transmission line is configured for transmission mode

The invention claimed is: 40 phase detection.
 1. A microfabricated sensor comprising: 18. The sensor according to claim 1 wherein the fluid at least one hollow microneedle for extraction of a sample channel has a width

extracted by the at least one microneedle, $\frac{45}{20}$. The sensor according to claim 1 wherein the fluid a microwave transmission line coupled to and extending channel is microfabricated in a channel plate.

the microwave transmission line, such that the dielec-
22. The sensor according to claim 1, wherein the at least
tric properties of the fluid in the fluid channel provide $\frac{50}{20}$ one microneedle is at least partly sur

an influence on the energy of the electrical properties of the electrical properties of the trans - structure dimensioned to support the tip of a finger is a ring . The sensor according to claim 1 wherein the fluid structu

and the walls of the fluid channel are electrically conductive wave transmission line is fabricated in a transmission line and connected to the ground plane.

extion of the microneedle.
 4. The sensor according to claim 3 wherein the at least one 65 by the at least one microneedle, and a microwave transmission line coupled to and extending along at least a portion of extension of the microneedle. The microneed the fluid channel so that bodily fluid in the channel forms a

dielectric medium in the microwave transmission line, such wave transmission line coupled to and extending along
that the dielectric properties of the fluid in the fluid channel at least a portion of the fluid channel so t that the dielectric properties of the fluid in the fluid channel at least a portion of the fluid channel so that bodily fluid provide an influence on the electrical properties of the in the channel forms a dielectric mediu

-
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- 10 Example the section of the second face of the channel wafer,

protruding from the first face of the silicon wafer;

extracting the sample of bodily fluid through the at least

extracting the sample of bodily fluid through
-
-
- assembling the channel wafer and the transmission line
substrate wafer such that the microwave transmission 15 detecting the component based on the performed RF substrate wafer such that the microwave transmission 15 of $\frac{1}{2}$ on $\frac{1}{2}$ detecting the component based on the performed RFF on line is coupled to and extends along at least the portion of the fluid channel.

27. The method according to claim 26 wherein the chan-
nel wafer is a silicon wafer and wherein the transmission line frequency or pulsed measurement.

28. The method according to claim 26 wherein the at least frequency or pulsed measurement comprises detection or measuring a phase change. one microneedle is formed in the channel wafer by deep reactive ion etching.

29. Method of detecting a component in bodily fluid of a
patient is blood and/or interstitual fluid.
 $\frac{33}{3}$. The method according to claim 29 wherein the com-
ponent is glucose.

providing a microfabricated sensor having at least one ponent is glucose.

14. The method according to claim 29 wherein the swept fluid, a fluid channel connected to the at least one frequency measurement is performed at a center frequency measurement is performed at a center of health. And a choose 1 GHz. microneedle for receiving a sample of bodily fluid extracted by the at least one microneedle, and a micro-

transmission line, the method comprising:
providing a channel wafer, having a first and a second 5 and 5 and 5 are fluid in the fluid channel provide an
influence on the electrical properties of the transmis-
influence on

- sion line substrate wafer; and frequency or pulsed measurement on the fluid sample;
sion line substrate wafer; and and and and and and and and $\frac{1}{2}$ and $\frac{1}{2}$ and $\frac{1}{2}$ and $\frac{1}{2}$ and $\frac{1}{2}$ and $\frac{1}{2}$
	-

30. Method according to claim 29 comprising determining the level of the component based on the performed swept

substrate wafer is a since water and wherein the transmission line
substrate wafer is a glass wafer, assembled by bonding.
29 The meaturement comprises detecting and/
29 The meaturement substrate a glass wafer is a gl

32. The method according to claim 29 wherein the bodily fluid is blood and/or interstitial fluid.

hollow microneedle for extraction of a sample of bodily 34. The method according to claim 29 wherein the swept
frequency measurement is performed at a center frequency